

Description

This invention relates generally to a lightsafe masking film and, more specifically, to a composite, lightsafe masking film to be used as an original copy having a transparent pattern in the photomechanical reproduction process.

One known lightsafe masking film of this type is composed of a plastic film substrate and a peelable, lightsafe layer provided thereon. When a desired cutting line is formed on the lightsafe layer manually or with a suitable automatic cutting device and when the cut portion is removed by peeling, there is left a desired transparent pattern on the masking film.

The lightsafe layer is generally composed of a binder and a lightsafe substance such as a colorant capable of blocking light having a wavelength of 550 nm or less. As a component of the binder, a nitrile rubber containing about 33 % by weight of acrylonitrile (such as Nipol 1432J (trademark)) has been generally used. See, for example, Patent Abstracts of Japan, Vol.7, No.216 (P-225) [1361], 24th September 1983. It has been found, however, that a lightsafe layer containing such a nitrile rubber is not fully satisfactory with respect to its properties such as cracking tendency, elongation tendency, small portion retentivity and blocking-preventing property. In particular, the physical properties are susceptible to temperature variation and, especially, the light safe layer tends to be cracked at a temperature of below 15 °C, Patent Abstracts of Japan, Vol.10, No.290 (P-503) [2346], 2nd October 1986, uses as the binder a mixture of an acrylic rubber and a vinyl chloride resin.

The present invention has been made to overcome the above-described drawbacks of the conventional masking film and provides a lightsafe masking film, comprising a transparent substrate, and a peelable lightsafe layer provided over the surface of said substrate and comprising (a) a lightsafe substance, (b) a copolymer containing vinyl chloride, (c) a mixture of a first nitrile rubber containing 25-30 % by weight of acrylonitrile and a second nitrile rubber containing 31-35 % by weight of acrylonitrile, and (d) an organopolysiloxane in an amount of 0.1-1.5 % by weight based on the total weight of said components (b) and (c).

The present invention will now be described in detail below.

Lightsafe masking film according to the present invention is preferably comprised of a transparent substrate formed of a plastics material having provided thereon a peelable, transparent, lightsafe layer.

Any plastics material conventionally used as a transparent substrate in known lightsafe masking films can be used for the purpose of the present invention. Synthetic resin films, semisynthetic resin films and laminated films thereof may be used as the substrate. Illustrative of suitable synthetic resin films are those formed of a polyester such as polyethylene terephthalate or polybutylene terephthalate, an aromatic polyamide, an aliphatic polyamide, a polyolefin such as polyethylene or polypropylene, a polystyrene, a polycarbonate, a polyvinyl chloride and a polyvinylidene chloride. Illustrative of a suitable semisynthetic resin film is that formed of a cellulose acetate. Examples of the laminated films include those using a combination of synthetic resin layers, a combination of synthetic resin and semisynthetic resin layers, and a combination of a cellulose layer and a synthetic resin layer and/or a semisynthetic resin layer. Above all, a polyethylene terephthalate film is an especially preferred substrate for reasons of excellent dimensional stability and excellent tensile strength and tearing strength. The thickness of the film is generally in the range of 20-300 μ m, preferably 50-250 μ m. Both stretched and non-stretched films may be used as the substrate.

The substrate is overlaid with a peelable, lightsafe layer generally composed of a binder, and a lightsafe or light-shading substance.

It is important that a combination of (a) a copolymer containing vinyl chloride, (b) a mixture of a first nitrile rubber containing 25-30 % by weight of acrylonitrile and a second nitrile rubber containing 31-35 % by weight of acrylonitrile, and (c) an organopolysiloxane should be used as the binder.

As the vinyl chloride-containing copolymer, there may be mentioned a vinyl chloride-vinylidene chloride copolymer, a vinyl chloride-vinyl acetate copolymer, a vinyl chloride-acrylic ester copolymer and a vinyl chloride-vinyl acetate-maleic acid terpolymer. These vinyl chloride-containing copolymers may be used by themselves or as a mixture of two or more.

The first and second nitrile rubbers to be used in conjunction with the vinyl chloride-containing copolymer may be, for example, copolymers of acrylonitrile and butadiene, acrylonitrile-butadiene rubbers or terpolymers of acrylonitrile, butadiene and a carboxyl group-containing copolymerizable monomer. Especially preferred is the use of a nitrile rubber containing about 27 % by weight of acrylonitrile as the first nitrile rubber and a nitrile rubber containing about 33 % by weight of acrylonitrile as the second nitrile rubber.

The weight ratio of the first nitrile rubber to the second nitrile rubber is preferably in the range of 4:1 to 1:4, more preferably 3:1 to 1:2, most preferably 2:1 to 1:1. The vinyl chloride-containing copolymer is generally used in an amount of 50-95 % by weight, preferably 60-90 % by weight based on the total of the weight of the first and second nitrile rubber and the vinyl chloride-containing copolymer.

The liquid organopolysiloxane which forms the third component of the binder may be, for example, a dimethylpolysiloxane, a methylethylpolysiloxane, a methylphenylpolysiloxane, a methylvinylpolysiloxane, a copolymer of dimethylpolysiloxane and an oxyalkylene or a polysiloxane modified with a higher alkyl. The organopolysiloxane is used in an amount of 0.01 to 1.5 % by weight based on the total weight of the vinyl chloride copolymer and nitrile rubbers.

The conjoint use of the first and second nitrile rubber, the vinyl chloride-containing copolymer and the organopolysiloxane can solve the above-mentioned problems of the conventional masking films. That is, such a conjoint use can improve the peelability of the resulting lightsafe layer. Moreover, it can afford a lightsafe layer having improved anti-cracking property, lengthening property, small portion retentivity and blocking-preventing property. The liquid organopolysiloxane improves adhesivity of the lightsafe layer to the substrate without adversely affecting peelability.

The kind and color of the lightsafe substance to be incorporated into the lightsafe layer are not specifically limited as long as the resulting lightsafe layer can block light having a wavelength of 300-550 nm. Red, yellow or amber colorants of an oil-soluble type, a direct dye-type, a reaction-type, or an acidic-type may be suitably used. Two or more colorants can be used in combination. Colorant soluble in an organic solvent is generally used for reasons of easiness of formation of the lightsafe layer on the substrate. The lightsafe substance is used in an amount so that the resulting lightsafe layer can block light having a wavelength of 300-550 nm.

The lightsafe layer may, if desired, contain a filler. While both organic and inorganic fillers may be used, the use of organic ones is more preferable. Examples of suitable inorganic fillers include silica, clay and alumina. Examples of suitable organic fillers include a cross-linked polystyrene, a benzoguanamine-formaldehyde condensation product, a polyamide (e.g. 6,6-nylon, 6-nylon or 12-nylon), a silicone resin, a crystalline cellulose, a phenol-formaldehyde resin, a fluororesin, a polyethylene resin or an acrylic resin. Of these fillers the use of polystyrene beads is particularly preferred, because they are effective in improving homogeneity of a coating composition for the formation of the lightsafe layer, in improving peelability of the lightsafe layer from the substrate while maintaining desired bonding therebetween, in suppressing reflection of light on the surface of the lightsafe layer, and in reducing the surface tackiness of the lightsafe layer.

The filler preferably has a particle size of 0.5-20 μm , more preferably 2-15 μm and is preferably used in an amount of 0.1-30 %, more preferably 0.5-20 % based on the weight of the binder.

The lightsafe layer may be prepared by any known manner such as by applying a coating composition containing the above ingredients on the surface of the substrate. A solvent such as an alcohol, an ester, a hydrocarbon, a halogenated hydrocarbon, a ketone or the like organic solvent can be used for the formation of the coating composition. The coating composition may further contain a leveling agent and a plasticizer, if desired. The lightsafe layer generally has a thickness of 10-50 μm , preferably 20-40 μm .

It is possible to provide a pressure sensitive adhesive layer between the substrate and the lightsafe layer so that the resulting masking film may permit the reuse of a cut lightsafe layer, peeled off from the substrate, for resticking. Such an adhesive layer is formed of a synthetic resin adhesive such as an acrylate ester copolymer, a saturated polyester or a polyurethane, or a rubber adhesive such as a natural rubber, a chloroprene rubber, isoprene rubber or a nitrile rubber.

The lightsafe masking film according to the present invention may be suitably used for the masking of a roomlight photosensitive material, such as of a silver halide-type or a photopolymer-type, which is sensitive to light with wavelengths of 400 nm or less.

The following examples will further illustrate the present invention. In the examples, "parts" are by weight. The test methods and evaluation of the test results in the following examples are as follows:

(1) Peelability:

Lightsafe layer of sample masking film, is cut with a cutter knife into square patterns and one of the squares is peeled off with the fingers from its corner. Peelability is evaluated and rated as being good or bad.

(2) Bonding strength:

Using a surface property measuring machine HEIDON 14 (Shintosh Manufacturing K. K.), the force required for peeling off the lightsafe layer is measured.

(3) Blocking tendency:

Two masking films are superimposed with the substrate of the upper masking film contacting with the lightsafe layer of the lower masking film. The two films are then allowed to stand at a temperature of 50 ° C and a relative humidity of 80 % for 5 hours while applying a load of 25 g/m² to the films. Tendency of the films to stick to each other at their area of contact is examined and is rated as follows:

- 5: No blocking
- 4: Blocking occurs very slightly
- 3: Blocking occurs partly
- 2: Blocking occurs over a greater part of the area
- 1: Blocking occurs over entire area

(4) Cracking tendency:

Tendency of lightsafe layer to crack during peeling is checked and is rated as follows:

- 5: No cracking
- 4: Hardly cracks
- 3: Cracking occurs partly
- 2: Relatively easily cracks
- 1: Very easily cracks

(5) Tendency to lengthen:

The degree of stretching of the lightsafe layer during peeling operation is evaluated and rated as follows:

- 5: Considerably lengthened
- 4: Fairly lengthened
- 3: Moderately lengthened
- 2: Slightly lengthened
- 1: Not at all lengthened

(6) Small pattern retentivity:

The lightsafe layer is cut to form circular patterns having diameters ranging from 0.5 to 5 mm and spaced apart with a distance of 1 mm. The remainder portion of the lightsafe layer is peeled off. The surface of the masking film having lightsafe circular patterns is rubbed. The ease with which the circular patterns can be peeled off is evaluated and rated as follows:

- 5: Not peeled off at all
- 4: A greater part of circular patterns remain unpeeled
- 3: About half of circular patterns remain unpeeled
- 2: A greater part of circular patterns are peeled off
- 1: All of the circular patterns are peeled off

(7) Tendency curl:

Lightsafe layer of sample masking film is cut with a cutter knife into squares with a side length of 1 m. The masking film is then placed on a flat table with the lightsafe layer being upside and is allowed to stand at room temperature for 24 hours. Each corner of the film is checked to see degree of curling of the film in terms of the height of the corner of the film from the table surface. Curling tendency is rated as follows:

- 3: less than 2 mm
- 2: between 2 - 5 mm
- 1: more than 5 mm

Examples 1-5

A coating composition was prepared by mixing 38.7 parts of a mixed solution composed of a first 20 % solution of a nitrile rubber (N-27, acrylonitrile content: 27 % by weight) in methyl ethyl ketone and a second 20 % solution of a nitrile rubber (N-33, acrylonitrile content: 33 % by weight) in methyl ethyl ketone, 72.1 parts of a 25 % solution of a vinyl chloride/vinyl acetate/maleic acid terpolymer (monomer ratio: 86:13:1, DENKA VINYL 1000C manufactured by Denki Kagaku Kogyo K. K.) in methyl ethyl ketone, 7.7 parts of a colorant (Valiozol Orange 3210T), 0.28 part of fine particulate polyethylene, 0.05 parts of an organosiloxane (SILICONE KP-356, manufactured by Shinetsu Kagaku Kogyo K.K. and 3.5 parts of methyl ethyl ketone. The weight ratio of the first solution to the second solution of the mixed solution are as shown in Table 1 below.

The coating composition was then uniformly applied over the surface of a polyethylene film (thickness: 75 μm) by a roll coater method and the coat was dried at 100 °C to obtain a masking film composed of the polyethylene film substrate having provided thereon a lightsafe layer with a thickness of 25 μm . The resulting masking film was then subjected to various tests to obtain the results shown in Table 1.

Comparative Examples 1 and 2

Example 1 was repeated in the same manner as described except that N-27 and N-33 were used by themselves. The masking films showed the test results as shown in Table 1.

Table 1

Example	Comp.1	1	2	3	4	5	Comp.2
N-27/N-33 ratio	4/0	3/1	2/1	1/1	1/2	1/3	0/4
Bonding strength (g/cm)	120	110	110	110	100	90	90
Blocking tendency	4	4	4	4	3	3	2
Peelability	good	good	good	good	good	good	good
Cracking tendency (25°C)	5	5	4	4	3	3	3
(10°C)	4	4	3	3	2	2	1
Tendency to lengthen (25°C)	3	3	3	3	3	3	2
(10°C)	3	3	3	2	2	2	1
Small pattern retentivity (25 °C)	4	4	4	4	3	3	2
(10 °C)	3	3	3	3	2	2	1
Curling tendency	1	2	3	3	3	3	3

Claims

1. A lightsafe masking film, comprising a transparent substrate, and a peelable lightsafe layer provided over the surface of said substrate and comprising (a) a lightsafe substance, (b) a copolymer containing vinyl chloride, (c) a mixture of a first nitrile rubber containing 25-30 % by weight of acrylonitrile and a second nitrile rubber containing 31-35 % by weight of acrylonitrile, and (d) an organopolysiloxane in an amount of 0.01-1.5 % by weight based on the total weight of said components (b) and (c).
2. A masking film as set forth in claim 1, wherein said first and second nitrile rubbers are copolymers of acrylonitrile and butadiene or terpolymers of acrylonitrile, butadiene and a carboxyl group-containing copolymerizable monomer.
3. A masking film as set forth in claim 2, wherein the contents of acrylonitrile in said first and second nitrile rubbers are about 27 % by weight and about 33 % by weight, respectively.
4. A masking film as set forth in any preceding claim, wherein the weight ratio of said first nitrile rubber to said second nitrile rubber is in the range of 4:1 to 1:4.

Table 1

Example	Comp.1	1	2	3	4	5	Comp.2
N-27/N-33 ratio	4/0	3/1	2/1	1/1	1/2	1/3	0/4
Bonding strength (g/cm)	120	110	110	110	100	90	90
Blocking tendency	4	4	4	4	3	3	2
Peelability	good	good	good	good	good	good	good
Cracking tendency (25°C)	5	5	4	4	3	3	3
(10°C)	4	4	3	3	2	2	1
Tendency to lengthen (25°C)	3	3	3	3	3	3	2
(10°C)	3	3	3	2	2	2	1
Small pattern retentivity (25 °C)	4	4	4	4	3	3	2
(10 °C)	3	3	3	3	2	2	1
Curling tendency	1	2	3	3	3	3	3

Claims

1. A lightsafe masking film, comprising a transparent substrate, and a peelable lightsafe layer provided over the surface of said substrate and comprising (a) a lightsafe substance, (b) a copolymer containing vinyl chloride, (c) a mixture of a first nitrile rubber containing 25 - 30 % by weight of acrylonitrile and a second nitrile rubber containing 31 - 35 % by weight of acrylonitrile, and (d) an organopolysiloxane in an amount of 0.01 - 1.5 % by weight based on the total weight of said components (b) and (c).
2. A masking film as set forth in claim 1, wherein said first and second nitrile rubbers are copolymers of acrylonitrile and butadiene or terpolymers of acrylonitrile, butadiene and a carboxyl group - containing copolymerizable monomer.
3. A masking film as set forth in claim 2, wherein the contents of acrylonitrile in said first and second nitrile rubbers are about 27 % by weight and about 33 % by weight, respectively.
4. A masking film as set forth in any preceding claim, wherein the weight ratio of said first nitrile rubber to said second nitrile rubber is in the range of 4:1 to 1:4.



5. A masking film as set forth in claim 4, wherein the weight ratio of said first nitrile rubber to said second nitrile rubber is in the range of 3:1 to 1:2.
6. A masking film as set forth in claim 5, wherein the weight ratio of said first nitrile rubber to said second nitrile rubber is in the range of 2:1 to 1:1.
7. A masking film as set forth in any preceding claim, wherein said vinyl chloride - containing copolymer is a vinyl chloride/vinylidene chloride copolymer, a vinyl chloride/vinyl acetate copolymer, a vinyl chloride/acrylic ester copolymer or a vinyl chloride/vinyl acetate/maleic acid terpolymer.
8. A masking film as set forth in any preceding claim, wherein said lightsafe layer further comprises (e) a filler.
9. A masking film as set forth in claim 8, wherein said filler is an organic filler selected from a cross-linked polystyrene, a benzoguanamine - formaldehyde condensation product, a polyamide, a silicone resin, a crystalline cellulose, a phenol - formaldehyde resin, a fluororesin, a polyethylene resin and an acrylic resin or an inorganic filler selected from silica, clay and alumina.
10. A masking film as set forth in claim 8 or claim 9 wherein said filler has a particle size of 0.5 - 20 μm .
11. A masking film as set forth in any preceding claim, wherein said organopolysiloxane is a dimethylpolysiloxane, a methylethylpolysiloxane, a methylphenylpolysiloxane, a methylvinylpolysiloxane, a copolymer of dimethylpolysiloxane and an oxyalkylene or a polysiloxane modified with an alkyl.

Patentansprüche

1. Lichtschutz - Maskierungsfilm, der ein durchsichtiges Substrat und eine über der Oberfläche des Substrates vorgesehene abziehbare Lichtschuttschicht umfasst, und folgendes umfasst: (a) eine Lichtschutzsubstanz, (b) ein Copolymer, das Vinylchlorid enthält, (c) eine Mischung eines ersten Nitrilkautschuks, der 25 - 30 Gewichts% Acrylnitril enthält, und eines zweiten Nitrilkautschuks, der 31 - 35 Gewichts% Acrylnitril enthält, und (d) ein Organopolysiloxan in einer Menge von 0,01 - 1,5 Gewichts%, die auf dem Gesamtgewicht der Komponenten (b) und (c) beruht.
2. Wie in Anspruch 1 dargestellter Maskierungsfilm, in dem die ersten und zweiten Nitrilkautschuke Copolymere von Acrylnitril und Butadien oder Terpolymere von Acrylnitril, Butadien und einem copolymerisierbaren Monomer, das eine Carboxylgruppe enthält, sind.
3. Wie in Anspruch 2 dargestellter Maskierungsfilm, in dem die Gehalte von Acrylnitril in den ersten und zweiten Nitrilkautschuken jeweils ungefähr 27 Gewichts% und ungefähr 33 Gewichts% sind.
4. Wie in einem der vorhergehenden Ansprüche dargestellter Maskierungsfilm, in dem das Gewichtsverhältnis des ersten Nitrilkautschuks zu dem zweiten Nitrilkautschuk in dem Bereich von 4:1 bis 1:4 liegt.
5. Wie in Anspruch 4 dargestellter Maskierungsfilm, in dem das Gewichtsverhältnis des ersten Nitrilkautschuks zu dem zweiten Nitrilkautschuk in dem Bereich von 3:1 bis 1:2 liegt.
6. Wie in Anspruch 5 dargestellter Maskierungsfilm, in dem das Gewichtsverhältnis des ersten Nitrilkautschuks zu dem zweiten Nitrilkautschuk in dem Bereich von 2:1 bis 1:1 liegt.
7. Wie in einem der vorhergehenden Ansprüche dargestellter Maskierungsfilm, in dem das Copolymer, das Vinylchlorid enthält, ein Vinylchlorid/Vinylidenchloridcopolymer, ein Vinylchlorid/Vinylacetatcopolymer, ein Vinylchlorid/Acrylestercopolymer, oder ein Vinylchlorid/Vinylacetat/Maleinsäreterpolymer ist.
8. Wie in einem der vorhergehenden Ansprüche dargestellter Maskierungsfilm, in dem die Lichtschuttschicht weiterhin (e) einen Füllstoff umfasst.



9. Wie in Anspruch 8 dargestellter Maskierungsfilm, in dem der Füllstoff ein organischer Füllstoff ist, der von einem vernetzten Polystyren, einem Benzoguanamin - Formaldehyd - Kondensat, einem Polyamid, einem Siliconharz, einem kristallförmigen Zellstoff, einem Phenol - Formaldehyd - Harz, einem Fluoroharz, einem Polyethylenharz und einem Acrylharz ausgewählt wird, oder ein anorganischer Füllstoff, der von Siliciumdioxid, Ton und Aluminiumoxid ausgewählt wird.

10. Wie in Anspruch 8 oder anspruch 9 dargestellter Maskierungsfilm, in dem der Füllstoff eine Teilchengrösse von 0,5 - 20 μ m hat.

11. Wie in einem der vorhergehenden Ansprüche dargestellter Maskierungsfilm, in dem das Organopolysiloxan ein Dimethylpolysiloxan, ein Methylethylpolysiloxan, ein Methylphenylpolysiloxan, ein Methylvinylpolysiloxan, ein Copolymer von Dimethylpolysiloxan und einem Oxyalkylen, oder ein mit einem Alky modifiziertes Polysiloxan ist.

Revendications

1. Une pellicule à masquer protégeant de la lumière, comprenant un substrat, et une couche imperméable à la lumière pelable prévue sur la surface dudit substrat et comprenant (a) une substance imperméable à la lumière, (b) un copolymère contenant du chlorure de vinyle, (c) un mélange d'un premier caoutchouc nitrile contenant 25 - 30 % par poids d'acrylonitrile et un deuxième caoutchouc nitrile contenant 31 - 35 % par poids d'acrylonitrile, et (d) un organopolysiloxane en quantité de 0,01 - 1,5 % par poids à base du poids total desdits composants (b) et (c).

2. Une pellicule à masquer selon la revendication 1, dans laquelle lesdits premier et deuxième caoutchoucs nitriles sont des copolymères d'acrylonitrile et de butadiène ou des ter - polymères d'acrylonitrile, butadiène et un monomère copolymérisable contenant un groupe carboxyle.

3. Une pellicule à masquer selon la revendication 2, dans laquelle les teneurs en acrylonitrile desdits premier et deuxième caoutchoucs nitriles sont d'environ 27 % par poids et 33 % par poids respectivement.

4. Une pellicule à masquer selon une quelconque des revendications précédentes, dans laquelle le rapport du poids dudit premier caoutchouc nitrile au poids dudit deuxième caoutchouc nitrile est dans la plage de 4:1 à 1:4.

5. Une pellicule à masquer selon la revendication 4, dans laquelle le rapport du poids dudit premier caoutchouc nitrile au poids dudit deuxième caoutchouc nitrile est dans la plage de 3:1 à 1:2.

6. Une pellicule à masquer selon la revendication 5, dans laquelle le rapport du poids dudit premier caoutchouc nitrile au poids dudit deuxième caoutchouc nitrile est dans la plage de 2:1 à 1:1.

7. Une pellicule à masquer selon une quelconque des revendications précédentes, dans laquelle ledit copolymère contenant du chlorure de vinyle est un copolymère chlorure de vinyle/chlorure de vinylidène, un copolymère chlorure de vinyle/acétate de vinyle, un copolymère chlorure de vinyle/ester acrylique ou un terpolymère chlorure de vinyle/acétate de vinyle/acide maléique.

8. Une pellicule à masquer selon une quelconque des revendications précédentes, dans laquelle ladite couche imperméable à la lumière comprend en outre (e) une charge.

9. Une pellicule à masquer selon la revendication 8, dans laquelle ladite charge est une charge organique choisie à partir d'un polystyrène à liaison croisée, un produit de condensation de benzoguanamine - formaldéhyde, un polyamide, une résine silicone, une cellulose cristalline, une résine de phénol - formaldéhyde, une fluororésine, une résine de polyéthylène et une résine acrylique ou une charge inorganique choisie à partir de silice, argile et alumine.

10. Une pellicule à masquer selon la revendication 8 ou la revendication 9, dans laquelle ladite charge a une grandeur de particule de 0,5 - 20 micromètres.



11. Une pellicule à masquer selon une quelconque des revendications précédentes, dans laquelle ledit organopolysiloxane est un diméthyle-polysiloxane, un méthyle-éthylène polysiloxane, un méthyle-phényle-polysiloxane, un méthyle-vinyle-polysiloxane, un copolymère de diméthyle-polysiloxane et un oxyalcoylène ou un polysiloxane modifié avec un alkyle.

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